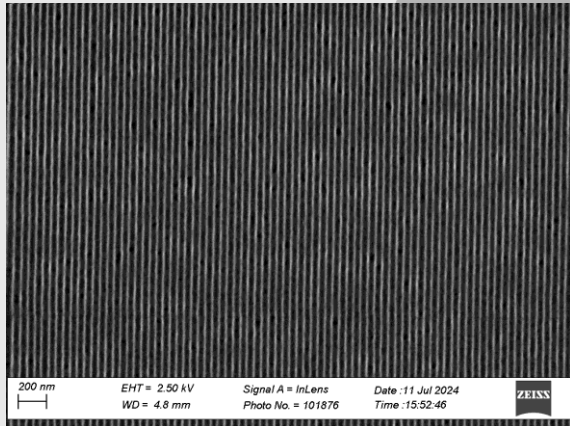
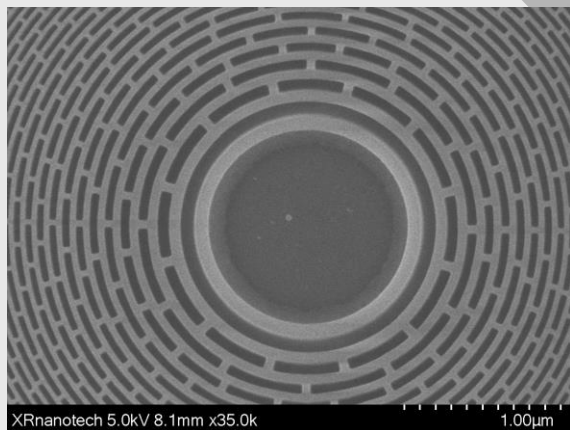


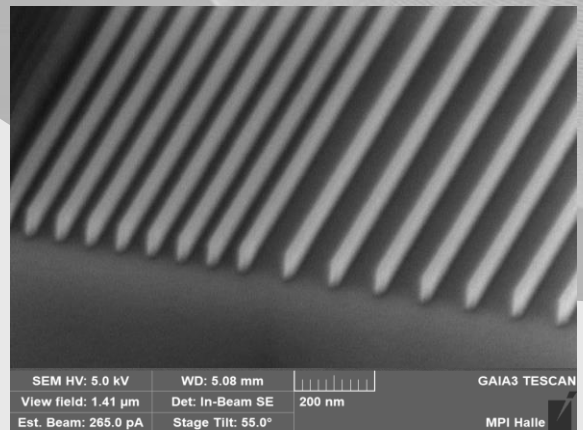
# New HSQ Formulation



Paul Scherrer Institut – Dr. Kevin Hofhuis –  
2% Solution



XRnanotech – Dr. Damien Eschimese –  
20% Solution



Max Plank Institute - Halle – Dr. Jiho Yoon –  
6% Solution

Available in  
concentrations  
from 1% to 40%

Improved stability

Improved line edge roughness

No change in established processing conditions